

JAN 30 2006

PATENT
Atty. Orl. No. APPM/008539/FE/EPVAG

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:
Yihawan Kim et al.

Serial No.: 10/683,937

Confirmation No.: 2191

Filed: October 10, 2003

For: Methods of Selective
Deposition of Heavily
Doped Epitaxial SiGe

Group Art Unit: 2822

Examiner: Michael Manh Trinh

MAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

CERTIFICATE OF FACSIMILE TRANSMISSION UNDER 37 CFR 1.8	
I hereby certify that this correspondence and the documents referred to as attached therein are being facsimile transmitted to the U.S. Patent and Trademark Office to the fax number indicated by the Examiner, namely, fax number 571-273-8300 to the attention of the named Examiner, on the date below.	
January 30, 2006 Date	<i>Kim & Sher</i> Signature

Dear Sir:

RESPONSE TO FINAL OFFICE ACTION DATED NOVEMBER 30, 2005

In response to the Final Office Action dated November 30, 2005, having a shortened statutory period for response set to expire on February 30, 2006, please enter this response and reconsider the claims pending in the application for reasons discussed below. Although the Applicant believes that no additional fees are due in connection with this response, the Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/APPM/008539/KMT, for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

Amendments to the Claims begin on page 2 of this paper. Remarks begin on page 9 of this paper.

Page 1